

<b>Notice of References Cited</b>	Application/Control No. 10/705,254		Applicant(s)/Patent Under Reexamination CAMPAGNOLA ET AL.	
	Examiner Cynthia Hamilton		Art Unit 1752	Page 1 of 1

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*	E	US-3,265,772	08-1966	STANLEY TOCKER	522/109
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	V	Thompson et al, eds , Introduction to Microlithography, Second Edition, ACS Professional Reference Book, American Chemical Society, Washington, DC 1994 pages 162-165.			
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)  
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.